Ion Plated Gold Films: Properties, Tribological Behavior and Performance

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In December, I wear and an extended endurance life, and also alter the adherence. Ion plated metallic films have exceptionally strong adherence which is attributed to a graded hardness as it affects the tribological performance characterized by effective lubrication.

Soft films confine friction losses to a thin, low shear strength film interposed between the contacting surfaces. Gold ion plated films are widely used in spaceborne bearings of various satellite mechanisms such as solar drives, de-spin assemblies and gimbals or rotating surfaces, and are finding increased application. The interface or transition from the substrate material to the coating usually forms a break or fused interface between the coating and the substrate. As a result, adherence, coherence, density, internal stresses, morphology, and defects in the coatings can be significantly improved, which in turn favorably affect the lubricating properties.

Adherence and Graded Interface

Strong adherence between the coating and the substrate is of paramount importance for any successful application. The interface or transition from the substrate material to the coating usually forms a break in the normally uniform crystallinity and/or composition. This abrupt disparity or mismatch is reflected in the coefficient of thermal expansion, thermal conductivity, and hardness. The objective is to reduce or eliminate this abrupt disparity by inducing a graded or fused interface between the coating and the substrate. The process of ion plating provides a gradual composition, or graded interface. This effect is illustrated with experimental results by analyzing ion plated gold films on nickel and iron surfaces by x-ray photoelectron spectroscopy (XPS) depth profiling as shown in Figs. 2(a) and (b) [7,8]. Compositions of surface (at %) for gold films ion-plated on nickel
and iron were obtained as functions of the sputtering removal time from XPS analysis. The composition of gold did not change in the first 20 min of sputtering and therefore the civilization was due to the continuously increasing sputtering time. However, the nickel and iron content increased with increased sputtering times. The graded interface for gold on nickel was approximately 6 μm thick; that for gold on iron was approximately 1.5 μm thick. The deeper graded interface between gold and nickel is due to the continuous gold solubility between the two metals. Since gold and iron have very limited solid solubility (1.5 at % at 850 °C) the interface was reduced and is basically produced by implantation and ionic atomic mixing. On the other hand, XPS depth profiles for gold vapor deposited nickel and steel surfaces are shown in Fig. 3. The composition of gold rapidly decreased with increasing sputtering time, thus forming an abrupt interface. The interface formation was also investigated by Micro-Vickers hardness measurements where indentation hardness depth profiles were established for the ion plated gold films on nickel substrates and are shown in Figs. 4(a) and (b). The microhardness of the ion plated gold film, graded gold-nickel interface and nickel substrate as a function of depth from the surface is shown in Fig. 4(a). The gold films were gradually removed by argon ion sputtering for microhardness measurements. Initially, the microhardness of the gold film is relatively low, but gradually increases in the interface region and finally decreases again as it reaches the nickel substrate. The higher hardness in this region is due to alloying effects. The vapor deposited gold film on nickel substrates shown in Fig. 4(b) exhibits a constant hardness, which indicated the lack of alloying. The XPS and microhardness depth profiles experimentally verify the formation of the gold graded fused interface which is responsible for the excellent adherence. The gold graded interface not only provides excellent adherence, but also induces a surface strengthening effect which improves the mechanical properties such as yield strength, tensile strength, and fatigue strength as shown in Figs. 5(a) and (b). The surface-subsurface strengthening may arise from solid-solution alloying, dispersion of mobile interstitial or substitutional atoms which act as barriers to the egress of dislocations.

Nucleation and Growth Morphology

During ion plating the evaporant flux of energetic ions and atoms transfers energy, momentum, and charge to the substrate and the depositing film surface. Because of the low ionization efficiency of the d-diode process, gold atoms are expected to arrive at the substrate with a range of energies. The high energy gold species arrive at the substrate with energies high enough to cause particle implantation into the substrate where they lose their energy, rather than diffuse over the surface. Continuous ion bombardment of the substrate during ion plating sputters off the loosely bonded atoms, thus leaving a state of high energy implanted particles which act as nucleation sites. Ion plated gold films unlike the conventional films exhibit a distinct nucleation behavior as shown in Figs. 6(a) to (c). The nuclei formed during ion plating exhibit distinct characteristics. The size is considerably smaller (150 Å) and has a high nuclei density with a uniform distribution. As deposition continues the nuclei remain rounded with only a slight increase in size, less than 20 percent, without the typical island coalescence which is typical for conventional nucleation. In classical nucleation, there is a decreasing tendency for them to become completely round after coalescence, consequently islands become elongated and join to form an irregular network structure. As deposition continues in ion plating, the existing nuclei grow, but formation of new nuclei continues to be a major growth mechanism [9]. Consequently, continuous films are formed in the 250 Å thickness range, with fine uniform grain structure, high packing density, and a minimum lattice misfit.

A typical ion plated gold film as compared to a vapor deposited one is shown in Fig. 7, where a high degree of nonuniformity in grain size and shape is obvious for the vapor deposited film.

Film Thickness Effects

The ultra thin and the thin film region with an effective or critical film thickness at which the friction coefficient reaches a minimum value is termed friction. Film thickness lower than that of minimum friction did not provide full surface coverage, and some steel to steel contact occurs. If film thickness is higher than the minimum friction, an increasing proportion of the load capacity was carried by the metallic film, thus progressively reducing the effect of the hard substrate. By reducing the thickness, the junction shearing strength is determined by the soft metallic film, while the contact surface and the yield point are determined by the properties of the support material. The relationship between the critical film thickness and the minimum friction is affected by the surface roughness and the deposition technique selected. With rough surfaces the friction coefficient increases continuously as the film thickness increases without going through a minimum [11,12].

Internal Stresses

The total internal stress is composed of the thermal stress \( \sigma_t \) and intrinsic stress \( \sigma_i \), where \( \sigma_{total} = \sigma_t + \sigma_i \). The thermal stress is due to the differences in the thermal expansion coefficient of the coating and the substrate material. Intrinsic stress is due to the accumulating effects of crystallographic defects or flows formed into the coating during deposition. Usually, the intrinsic stresses in the film are the dominant part of the total stress since they are microstructure-sensitive. During ion plating the presence of gas discharge and primarily the high energy of the incident atoms and ions increases the substrate temperature and favors the densification of the microstructure. As a result gold ion plated films generally show little or no internal stresses (approximately 5×10^6 dyn/cm²).

It should be also pointed out, that ion plated films in contrast to evaporated ones generally show compressive stresses instead of tensile. This should not be surprising, considering their dense microstructure.

Frictional Characteristics

Ion plated gold films because of their excellent adherence and dense film microstructure have found extensive uses in space born bearings of satellite mechanisms. Typical friction curves for ion plated and vapor deposited gold films 2000 Å thick as determined in a pin and disk tribotester under vacuum conditions are shown in Fig. 10. The ion plated Au films had three distinct improvements over the vapor deposited ones: (1) increased endurance life, (2) lower
coefficient of friction and (3) avoidance of catastrophic failure. The reasons for the increased endurance life are attributed to the superior adherence, the lower coefficient of friction due to the dense, cohesive small crystalline size and the optimum film thickness, and the gradual increase in the coefficient of friction after the film has been worn off to the formation of the graded interface. The graded gold interface formed during ion plating is of dual importance in gold film lubrication, since a graded interface which is generated is responsible for the excellent adherence and prevention of unexpected seizure at tribococontacts.

Conclusions

During ion plating the glow discharge energizing favorably modifies and controls the coating/substrate adherence and the nucleation and growth sequence. The graded interface formed not only guarantees an excellent adherence, but also induces a surface strengthening effect which improves the mechanical properties. The ion plated gold films 0.2 μm thick exhibit a distinct, improved film structure with an equiaxed, small grain size which is responsible for the high packing density and a minimum amount of lattice misfit. As a result, continuous, uniform films are obtained at lower nominal thicknesses which favorably affects the coefficient of friction. The strong adherence with the graded interface and the dense microstructure improves the tribological performance of sliding or rotating surfaces in terms of a lower coefficient of friction, lower wear, increased endurance lives and avoidance of catastrophic failure after lubricating film depletion.

REFERENCES

Figure 1. Ion plating system.

(a) Schematic.

(b) Ion plating chamber.
Figure 2. Elemental depth profiles for gold ion plated on nickel and iron. Film thickness, 0.6 μm.
Figure 3. - Element depth profiles for gold vapor deposited on copper, nickel, and 440C stainless steel. Film thickness, 0.3 μm.
Figure 4. - Hardness depth profiles for gold ion plated and vapor deposited on nickel substrate. Hardness measuring load, 0.1 N.
(a) Load elongation curves during tensile tests.

(b) Effect of ion plating on fatigue property of low carbon steel.

Figure 5. - Surface strengthening effects on mechanical properties.
Figure 6. - Transmission electron micrographs of gold during nucleation.
Figure 6. - Concluded.
Figure 7. - TEM micrograph of the crystal structure of a gold film.
Figure 8. - The variation of friction coefficient with gold film thickness (load 2.45N; speed 1.52 m min⁻¹; pressure 2x10⁻³ torr; roughness 0.02 μm).

Figure 9. - Schematic representation of the effect of film thickness on the friction coefficient of low shear strength metallic films on steel.
Figure 10. - Comparison of coefficient of friction of ion plated and vapor deposited gold film on 440C steel.
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Abstract

The glow discharge energizing favorably modifies and controls the coating/substrate adherence and the nucleation and growth sequence of ion plated gold films. As a result the adherence, coherence, internal stresses, and morphology of the films are significantly improved. Gold ion plated films because of their graded coating/substrate interface and fine uniform densely packed microstructure not only improve the tribological properties but also induce a surface strengthening effect which improves the mechanical properties such as yield, tensile, and fatigue strength. Consequently significant improvements in the tribological performance of ion plated gold films as compared to vapor deposited gold films are shown in terms of decreased friction/wear and prolonged endurance life.

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